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(54) **Power MOSFET semiconductor device and method of manufacturing the same**

(57) A semiconductor device includes a semiconductor substrate (11) of a first conductivity type, on which a semiconductor layer (12) having a trench (15) extending in the depth direction toward the semiconductor substrate (11) is formed. A first region (19) of the first conductivity type is formed in the depth direction along one side of the trench (15) in the semiconductor layer (12) and contacts the semiconductor substrate (11). A second region (25) of the first conductivity type is formed

in a surface area of the semiconductor layer (12) and close to the trench (15) and contacts the first region (19). A third region (26) of the second conductivity type is formed in the surface area of the semiconductor layer (12). A fourth region (27) of the first conductivity type is formed in a surface area of the third region (26). A gate insulation film and a gate electrode (29) are provided on the surface of the third region (26) between the second region (25) and the fourth region (27).

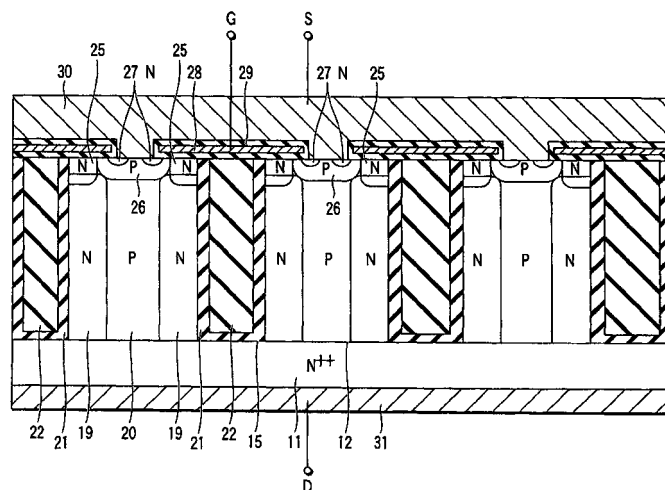


FIG.1

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EUROPEAN SEARCH REPORT

Application Number
EP 02 01 1514

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The present search report has been drawn up for all claims			
Place of search MUNICH		Date of completion of the search 8 June 2004	Examiner Lantier, R
<p>CATEGORY OF CITED DOCUMENTS</p> <p>X: particularly relevant if taken alone Y: particularly relevant if combined with another document of the same category A: technological background O: non-written disclosure P: intermediate document</p> <p>T: theory or principle underlying the invention E: earlier patent document, but published on, or after the filing date D: document cited in the application L: document cited for other reasons &: member of the same patent family, corresponding document</p>			

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**ANNEX TO THE EUROPEAN SEARCH REPORT
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For more details about this annex : see Official Journal of the European Patent Office, No. 12/82